Grain Size Distribution

d ₁₀	< 20 μm
d ₅₀	~ 8o µm
d ₉₀	> 160 µm
Specific Surface Area	-

Chemical Composition

Y ₂ O ₃	99.999%
Fe ₂ O ₃	< 0.005 %
SiO ₂	< 0.001 %
Na ₂ 0	< 0.043 %

These properties are typical but do not constitute specifications

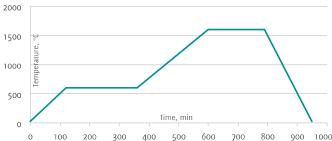
Physical Properties

Green Density 1)	2 00 g/cm ³
	2.98 g/cm³
Sintered Density 1)	4.98 g/cm³
Apparent Density	1.16 g/cm³
Flexural Strength	_
Shrinkage	~ 20 %
Δm ²⁾	~ 13 %
Color	white

1) at 200 MPa 2) weight loss after sintering

Recommended Sintering Conditions

Sintering Temperature	1600°C
Debinding	600°C
2000	



The shown debinding and sintering cycles are exemplary. More information on request.

Applications

Semiconductor Applications, for Cold Isostatic Pressing, Green Machining, Parts with Complex Geometry

Advantages.

- Excellent powder flowability and pressing behavior for low variance of die filling and green density.
- High dimensional accuracy after sintering, low dimensional scrap rate.
- Improved binder system with non-sticking properties on die surface. Reduced down time for mold cleaning.
- Formulation with eco-friendly carbon precursor. No use of phenolic resin. Clean and safe debinding process without toxic emissions. Reduced deposits inside debinding equipment provide for reduced maintenance down time.
- Reduced pressure to obtain the required green density. Reduced cost factor related to tool wear.



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